



Polydopamine Mediated Growth of Ag Nanostructures on ZnO Thin Films for Catalytic Degradation of Organic Dyes

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Highlights

- ZnO thin films were fabricated by RF magnetron sputtering technique.
- The growth of Ag NSs with polydopamine on ZnO thin film surface.
- The catalytic activity of the multi-functional films.
- Metal oxide films with plasmonic structures for efficient degradation of organic dyes.

Article Info

Received: 13/11/2019

Accepted: 02/06/2020

Keywords

ZnO thin film
Ag nanostructures
Polydopamine
Catalytic activity

Abstract

In this study, multi-functional films were produced by the solution-phase growth of plasmonic Ag nanostructures (NSs) on ZnO fabricated by RF magnetron sputtering technique. The Ag NSs was grown on ZnO coated surface by functionalizing the thin film with mussel-inspired polydopamine. The structural analysis was performed by Grazing Incident X-ray diffraction (GIXRD) and Fourier Transform Infrared Spectrometer (FTIR) technique in order to observe the effect of the Ag NSs deposition times. The effect of growth conditions on the structure and size of Ag NSs was investigated by Field Emission Scanning Electron Microscope (FESEM) imaging technique. The chemical compositions of as-deposited and Ag decorated ZnO films confirms using Energy-dispersive X-ray spectroscopy (EDX) analysis. The catalytic performance of the multi-functional films was investigated by the degradation of organic dyes (methyl orange (MO) and rhodamine B (RhB)). The catalytic activity of Ag on the is examined in details where it is found that maximum catalytic performance was observed within first 15 min for the ZnO thin films that were decorated with Ag NSs for 24h. The rate constant for the degradation reaction was $33.8 \times 10^{-3} \text{ min}^{-1}$ and $43.2 \times 10^{-3} \text{ min}^{-1}$ for MO and RhB, respectively. These results show the promise of integrating metal oxide films with plasmonic structures for efficient degradation of organic dyes.

1. INTRODUCTION

Organic compounds used as textile dyes, paints, pesticides, phenols and solvents have been widely used in industrial applications and daily life since the beginning of the 21st century. Uncontrolled release of these substances into the environment by wastewater containing organic and inorganic compounds that pollute water resources, and damage soil, plants, animals and human health [1,2]. The textile industry, which is one of the most used areas of dyestuff organic compounds, generates a large amount of wastewater with high concentrations of chemicals, and these wastes are the main causes of water pollution. Also, the wastewater produced by the textile dye industry is one of the main problems of environmental pollution as it contains aromatic amino compounds with high toxicity [3]. The complex aromatic structure of these compounds increases their resistance to temperature, chemicals, light, and other environmental factors, making them difficult to deteriorate in nature and prevents their effective purification by conventional purification methods [4].

The large reduction of water resources in the world threatens ecological life seriously. This threat has resulted in strong motivation for development of new technologies for the removal of organic pollutants from the aqueous environment. Conventionally, chemical, physical and biological methods are used for

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cleaning textile dyes in wastewater. These methods cannot separate substances due to the complex and stable structures of organic dyestuffs. Therefore, in recent years, the need for innovative treatment methods is inevitable [5]. Efficient treatment of organic pollutants by environmentally friendly photocatalysis method is noteworthy [6]. This method has considerable advantages over conventional methods due to its low energy consumption and easy reaction conditions [7]. In the photocatalysis method, organic pollutants are effectively removed by benefiting from photocatalytic properties of various metal oxide semiconductors under UV light. ZnO is one of the most researched metal oxides due to its large energy bandgap (3.36eV), high binding energy (60meV), inexpensive, anti-bacterial and environmentally friendly [8,9].

There are various surface modification studies to increase the photocatalytic activity of ZnO and other metal oxides [10]. These modifications are important because they facilitate reactions on the surface of the catalyst and broaden the absorption spectrum [11]. Modifying the surface structure of ZnO with metals such as Pt [12,13], Ag [14], Au [15] is the most effective way to accelerate the separation of the carrier charge from the surface and increase the catalytic efficiency.

In recent years, metallic NSs have increased significantly in their use in heterogeneous catalysis applications due to their superior catalytic properties [16]. These NSs are highly effective in reducing organic contaminants in the presence of reducing agents [17]. Like the photocatalytic mechanism, metal nanoparticles with electron relay effect can break down organic dyes without the need for any light source in the presence of NaBH₄ in the environment. The degradation of dyestuffs with catalyst is kinetically challenging but thermodynamically favorable. The NSs overcome the kinetic barrier for the degradation of the dyestuffs by creating alternative pathways that reduce the activation energy. Thus, very fast reactions can occur according to the photocatalytic degradation [18]. In the literature, it is possible to see a range of different studies for photocatalytic degradation, and the breakdown of dyestuffs using electron transfer are gaining increasing attention [19]. The challenges in the reusability and agglomeration of powder catalysts motivate research for catalytically active solid substrates [20]. The synergistic exploitation of metal oxide thin films decorated with metallic nanostructures show great potential for the degradation of organic dyes without any light source in the presence of NaBH₄ in the environment.

In this study, a multi-functional surface was produced by decorating plasmonic Ag NSs onto ZnO films fabricated by RF magnetron sputtering technique on Si (100) substrate. Various methods such as RF/DC magnetron sputtering, chemical vapor deposition (CVD), pulsed laser deposition (PLD), organic vapor phase epitaxy (MOVPE), molecular beam epitaxy (MBE), and sol-gel are used in the production of ZnO thin films [21,22]. Magnetron sputtering, in particular, enables tuning of the chemical composition and practically rates of film deposition. Furthermore, since the magnetron sputtering technique is carried out under high vacuum, it provides the possibility of producing a high purity, homogeneous and high-quality thin film. Surface growth of Ag NSs was realized by functionalization of the ZnO thin film with mussel-inspired polydopamine [23]. The solution-phase deposition of polydopamine enables versatile functionalization of the surface and provides chemical groups that are necessary for the reduction of Ag ions. The effect of growth conditions on the size and structure of Ag NSs was investigated by FESEM imaging technique. The produced multi-functional surfaces showed high levels of catalytic activity. The catalytic performance of the multi-functional films was investigated by the degradation of MO and RhB.

2. MATERIAL AND METHOD

2.1. ZnO Thin Film Growth

ZnO thin films were fabricated using RF magnetron sputtering method (NANOVAK[®] NVTS-400) on Si (100) substrate. ZnO target of 99.999% purity and argon gas of the same purity were used in the production of ZnO films. Before the deposition, Si (100) substrates were cleaned with ultrasonic cleaner using acetone, ethanol and dried by nitrogen gas blowing, respectively. The chamber was purged down to 2×10^{-6} Torr base pressure prior to the deposition. Thin films were fabricated under 4.5 mTorr pressure, 15 sccm argon flow rate, 75 W RF power and room temperature conditions. The deposition rate of ZnO thin films with a thickness of 250 nm was 0.4 Å/s. The thickness of the films was measured by the QCM thickness

measurement system (Inficon) during the growth process. Also, the thickness of the films was further verified with cross-sectional SEM imaging.

2.2. Growth of Ag NSs

Si (100) substrates ($1 \times 1 \text{ cm}^2$) with a 250 nm thick film of ZnO were immersed into a dopamine solution (dopamine hydrochloride (Sigma H8502), 1 mg/mL in 5 mM Tris-EDTA buffer, pH 8.5) at room temperature for 2 h. After the polydopamine (PD) coating, the samples were washed with distilled water. After the cleaning samples were dried by blowing N_2 gas. Then, PD coated substrates were treated with silver nitrate solution (50 mM AgNO_3 in 15 mL distilled water) in an orbital shaker system for different Ag growth times (12, 24 and 36h).

2.3. Characterization

The X-ray diffraction patterns of multi-functional thin films were analyzed using Grazing Incident X-ray diffraction (GIXRD) technique with Panalytical X-ray diffractometer in 2θ range of $30\text{--}80^\circ$. Microstructural, surface morphology and elemental analysis of the thin films were investigated using Field Emission Scanning Electron Microscope (FESEM, Zeiss Gemini 500). FTIR spectrum measurements of samples were taken in the range of $450\text{--}4000 \text{ cm}^{-1}$ using Fourier Transform Infrared Spectrometer (Perkin Elmer Spotlight 400 Imaging System). Perkin Elmer Lambda 25 was used as a UV–vis spectroscopy in the wavelength range of $300\text{--}650 \text{ nm}$ to monitor the catalytic degradation of methyl orange (MO) and rhodamine B (RhB). For catalytic degradation, dye molecules (MO & RhB) dissolved in aqueous solutions were prepared at a concentration of 1 mg/100ml. Before positioning the substrate in the solution, 1 M NaBH_4 freshly prepared in cold water was added to the solution while stirring and first absorbance spectrum was measured with UV–visible spectroscopy at this time. Then, the substrate was located on the holder in a glass beaker filled with 100 ml of solution. After that, the absorbance spectrum of the solution was measured at varying times (5, 10, 15, 20, 25, 30, 45 and 60 min.).

3. RESULTS

Figure 1 summarizes the growth of Ag NSs on top of sputter-coated films of ZnO. The first step consisted of deposition of a thin film of ZnO via RF magnetron sputtering. In order to decorate the ZnO thin film with Ag nanostructures, the substrate was functionalized with mussel inspired PD coating. The deposition of PD was simply performed by immersing the substrate in a buffered solution of dopamine. The self-polymerization of dopamine on the surface of solid substrates resulted in a layer of PD with a thickness that scaled with the immersion time. The thickness of the PD layer following 2h was found to be $2.1 \pm 0.1 \text{ nm}$. The catechol groups that are present in the PD layer provides reactive sites for reduction of metal salts [23]. In a solution of AgNO_3 , the substrate was decorated with Ag NSs. The growth of Ag NSs occurred in regions with an average diameter of $1.6 \pm 0.8 \text{ }\mu\text{m}$. The high magnification SEM imaging revealed the growth of columnar structures within these regions.

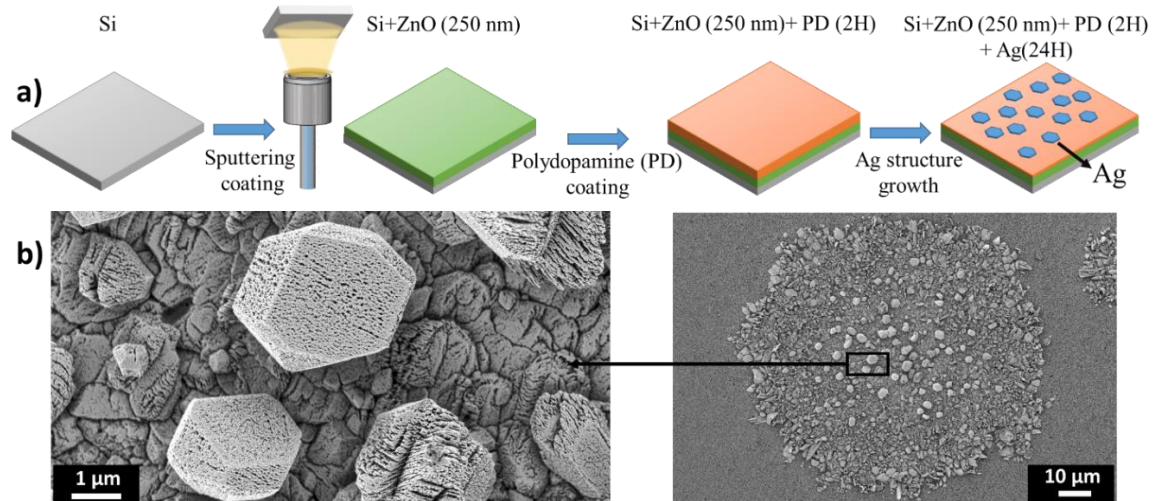


Figure 1. Growth of Ag NSs on top of ZnO thin films; a) Schematic description of the process b) SEM images of the Ag NSs

3.1. Structural Characterization Results

The XRD pattern for pure and Ag decorated ZnO thin films for various Ag deposition times showed in Figure 2. The (002) and (130) planes corresponding to the diffraction peaks at 34.2° and 62.6° indicate that the ZnO films are in good agreement with the wurtzite hexagonal crystal structure (JCPDS No. 36-1451) [24]. These peaks were not present in the absence of ZnO thin film for the PD coated, and Ag decorated PD thin films. The peak at 38.2° was attributed to diffraction from the (111) plane of face centered cubic structure Ag (JCPDS card # 089-3722) [20]. The peak intensity of the Ag on the uncoated PD on ZnO film was quite low. The maximum peak intensity for ZnO and Ag was observed for the substrates prepared by using 24h Ag deposition time. The peak intensity of the ZnO (002) plane increases with the Ag decoration time. But, after 24h, the intensity of the peak decreased despite the increase in Ag decoration time. This indicates that decorating the 24h Ag may improve ZnO (002) preference orientation but decorating the Ag for too long disrupts the orientation. In addition, the radius of the Ag^+ ion (1.22 \AA) is larger than the radius of the Zn^{2+} ions (0.74 \AA). When the Ag decoration time exceeds 24h, Ag occupies the interstitial regions of ZnO and preventing the ZnO film from growing in the direction of the c-axis.

The average crystallite sizes (D) of the samples were calculated using the Debye–Scherrer equation [25]

$$D = \frac{0.9\lambda}{\beta \cos\theta} \quad (1)$$

where λ , θ and β is the wavelength of X-ray radiation, Bragg's angle of the peaks and the angular width of peaks at FWHM, respectively. The average crystal size of pure ZnO was 7.7 nm, and this size varied with the Ag deposition time. The average crystallite size was 9.93 nm, 12.76 nm and 10.86 nm for ZnO films that were decorated with Ag for 12h, 24h and 36h, respectively. The absence of any additional peaks and shifts in the position of peaks suggests that Ag did not incorporate into the lattice of ZnO but were only present on the surface of ZnO [26,27].

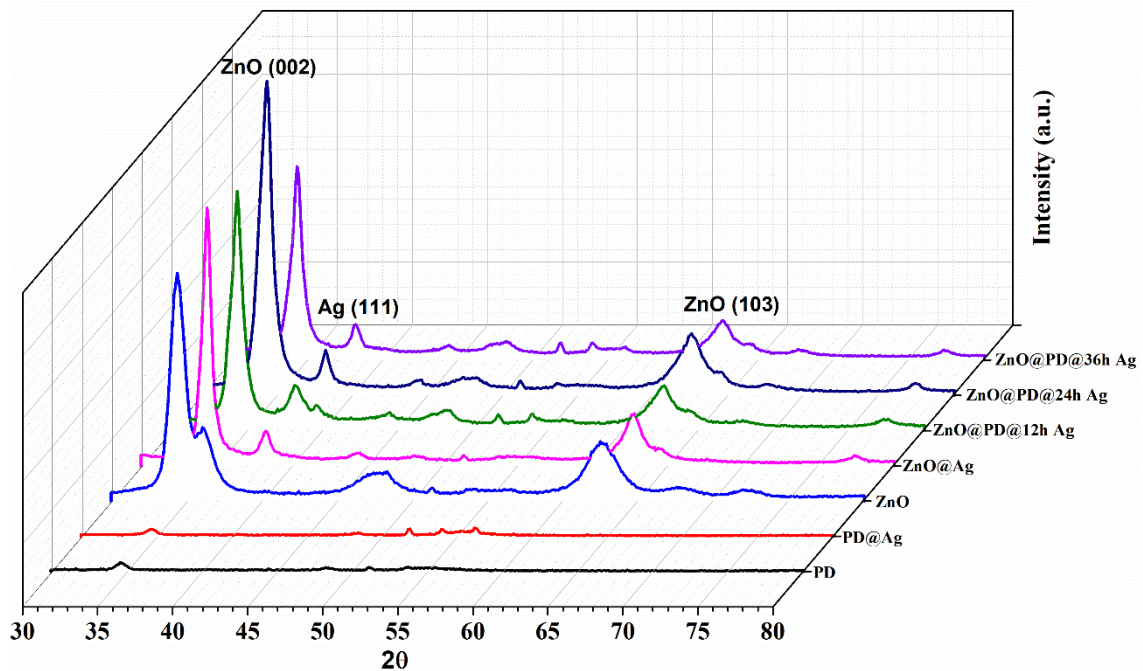


Figure 2. X-ray diffraction pattern of pure and Ag decorated ZnO thin films for varying Ag deposition times

SEM imaging was used for morphological characterization of as deposited and Ag decorated ZnO thin films. Figure 3 presents SEM images of pure and Ag decorated ZnO thin films prepared at different conditions. The ZnO film was highly uniform, free of any cracks, and consisted of nanoscale grains. The morphology of the surface exhibited significant change with the deposition of Ag. Control experiments in the absence of the PD coating did not result in the growth of Ag NSs. When PD was deposited on ZnO films, this layer allowed the growth of Ag NSs on the surface. The morphology of the substrates as a function of the Ag deposition time was investigated. The size of the Ag NSs was changed by growth time. When the growth time was 12h, the formation of Ag NSs was not complete. When the growth time increased to 24h, Ag NSs formed with an average size of 374 nm. Increasing the growth time to 36h, the average size of Ag NSs was reduced to 286 nm, likely due to the degradation of the underlying ZnO film in the aqueous growth solution. The growth of Ag NSs on ZnO film can be explained by metal ion reduction capabilities of PD. In the absence of PD, Ag nanostructures did not grow on the ZnO film. This result suggests the necessity of the functional groups provided by PD for the surface growth of Ag NSs. The growth of Ag was confined in micrometer sized regions. This localized growth is likely a result of the defect sites in the functionalization of the ZnO film with PD.

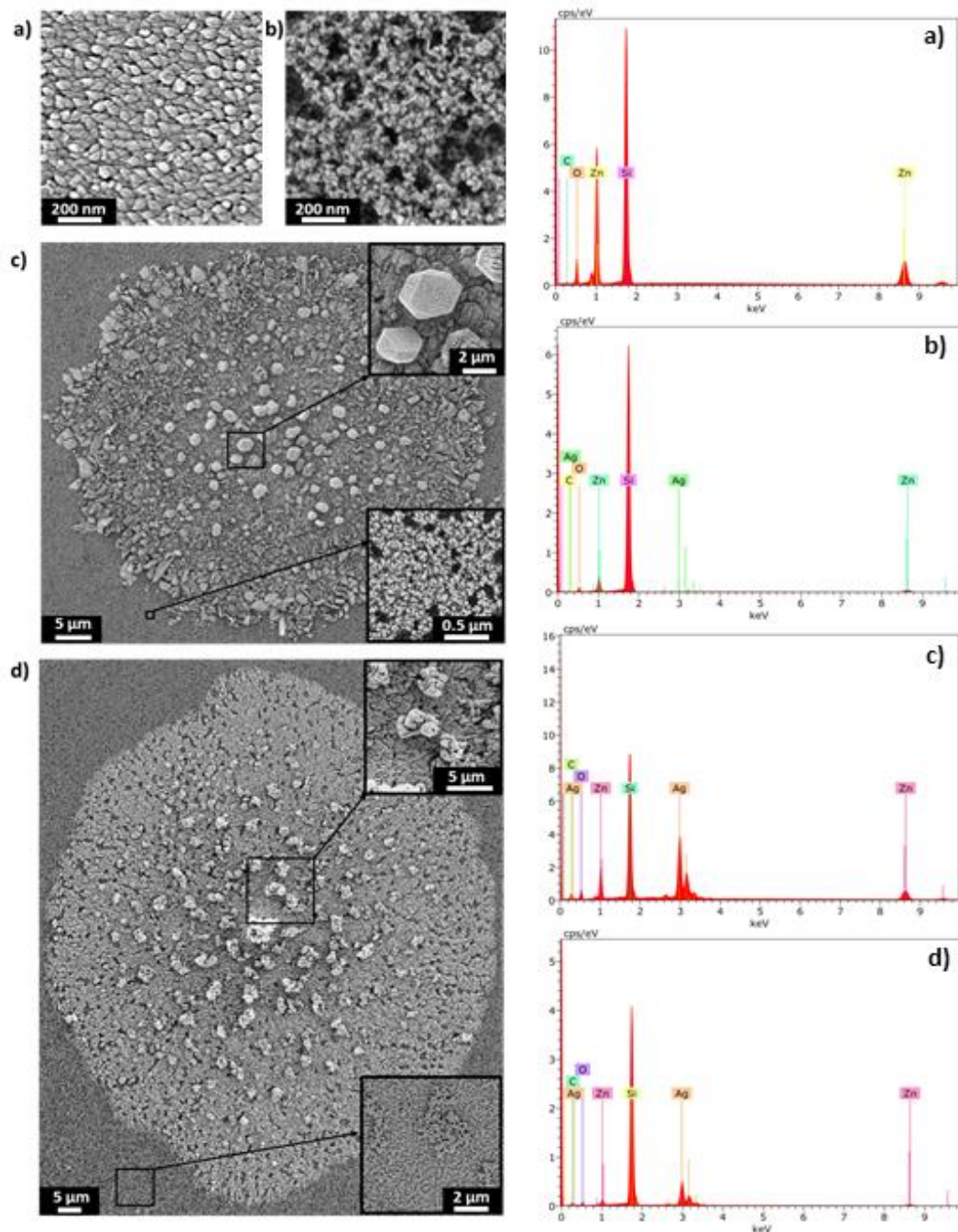


Figure 3. SEM images and EDX results of the substrates; a) As-deposited ZnO b) ZnO@PD@12h Ag c) ZnO@PD@24h Ag d) ZnO@PD@36h Ag

The chemical compositions of the as-deposited and Ag decorated ZnO thin films obtained from the EDX spectrum are shown in Figure 3. The elemental composition from the EDX spectrum confirmed the presence of Zn, O and Ag in the fabricated samples. The results show that Ag nanoparticles were successfully decorated on ZnO thin films.

The FTIR spectrum of as-deposited and Ag decorated ZnO thin films for varying Ag deposition times are shown in Figure 4. FTIR is a technique used to obtain information about the chemical bond structure of a material and to quickly establish the presence of various vibration modes in the samples. This technique is used to describe the main components of the material. The numbers and positions of the absorption peaks depend on the chemical composition, crystal structure and morphology of thin films. As-deposited ZnO and Ag decorated ZnO has a wurtzite crystal structure and this result is supported by the FTIR spectrum shown in Figure 4.

As seen in Figure 4, various vibration modes have been observed in different regions of the FTIR spectrum. The peak at 554 cm^{-1} is the typical characteristic peak of the pure ZnO hexagonal phase [28]. The peak at 1059 cm^{-1} is attributed to Si–O–Si bonds resulting from the silicon substrate. The vibration stress mode of the C=O bond was obtained at 1400 cm^{-1} . The absorption peak observed in 2338 cm^{-1} results from the atmospheric CO_2 . The peaks in 2914 cm^{-1} and 2970 cm^{-1} correspond to the stretching mode of the methylene groups.

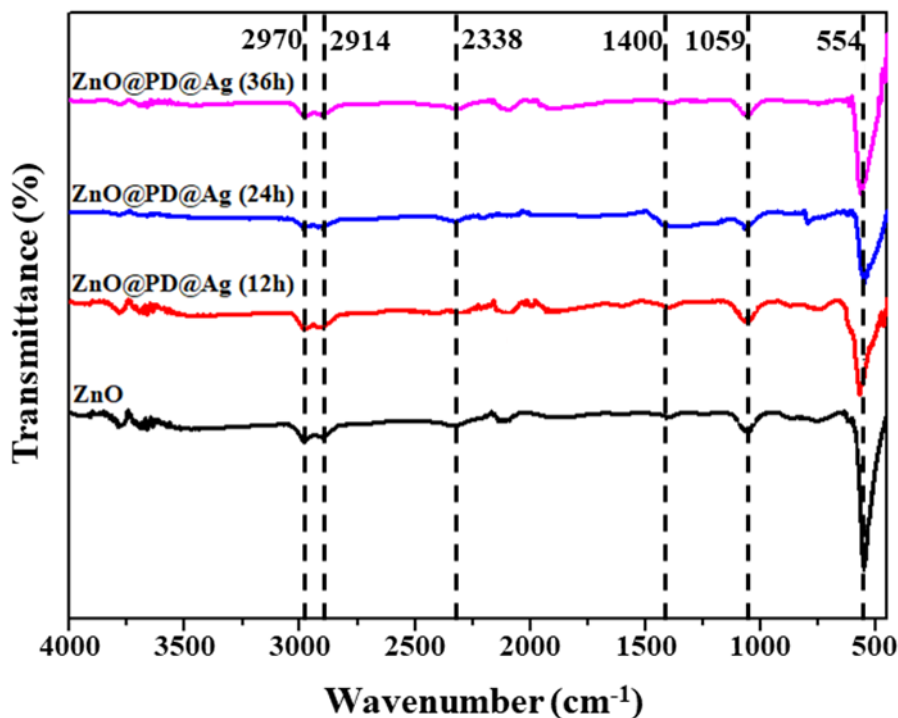


Figure 4. FTIR spectrum of as-deposited and Ag decorated ZnO thin films for varying Ag deposition times

3.1. Catalytic Performance

As-deposited and Ag decorated ZnO films absorption spectra at room temperature are given in Figure 5 (a). The absorption peaks around the 360 nm wavelength are the characteristic peak of ZnO. These absorption spectra showed that the films decorated with Ag shift the light absorption edge to red compared to pure ZnO, and this shift level increases with the Ag decoration time. Reduction of light absorption to red is a result of a decrease in band gap energy. This is due to Ag with a lower Fermi energy than ZnO. The catalytic degradation activities of the multi-functional thin films were analyzed in the absence and presence of the reducing agent. UV-visible absorption spectrums of MO and RhB solution taken at different times are shown in Figure 5 (b), (c). As clearly seen in Figure 5 (b), (c), the absorbance decreases for both MO and RhB dyes in the presence of NaBH_4 . Before the addition of NaBH_4 , the maximum absorbance peaks appeared at wavelengths of 464 nm and 553 nm for MO and RhB, respectively.

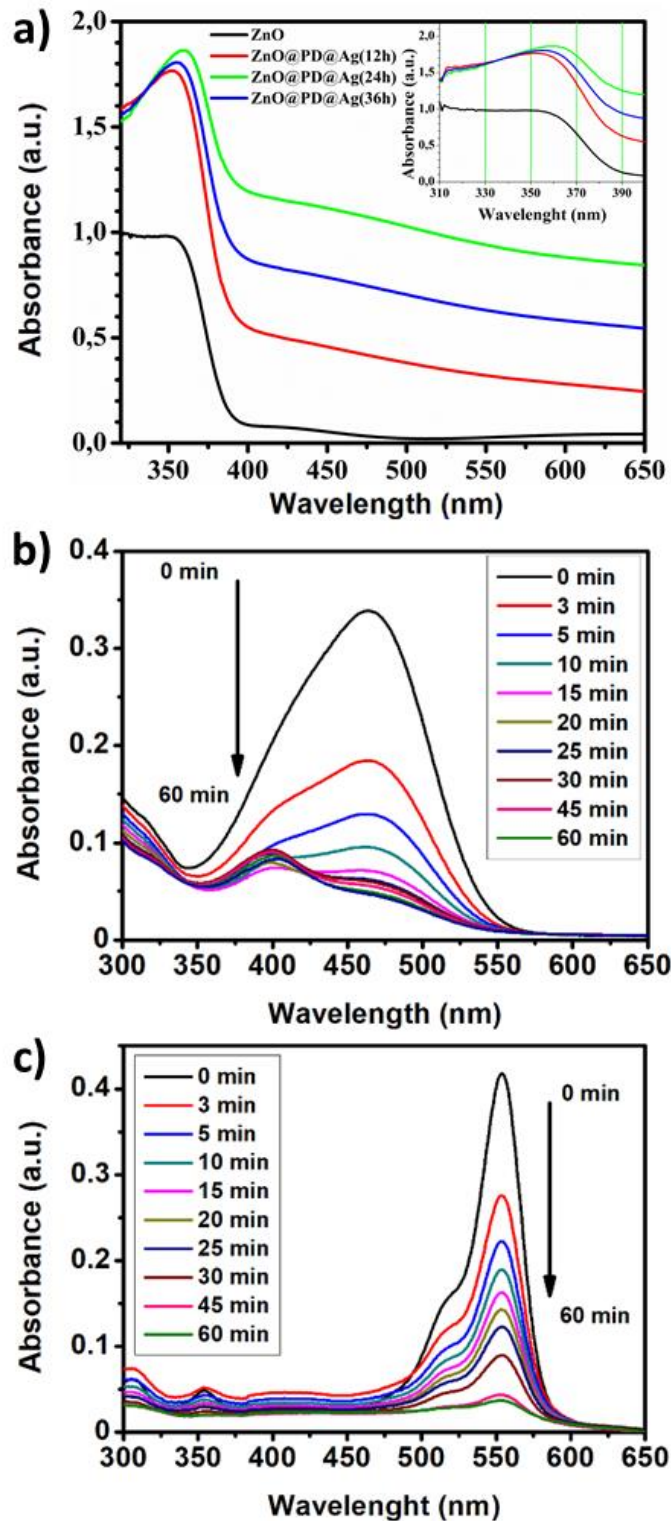


Figure 5. a) Uv-Visible absorption spectrum of samples; Time-dependent UV spectra of 24h Ag decorated ZnO thin films in different reducing agents b) MO c) RhB

When the reducing agent was added to the dye solution where Ag decorated ZnO thin film was present, the absorption peaks were reduced over time. Especially for MO, with the addition of NaBH_4 , the degradation occurred at high rates in the first 5 min. This high rate of degradation can be related with the interaction of RhB and the reducing agent with the catalytically active regions.

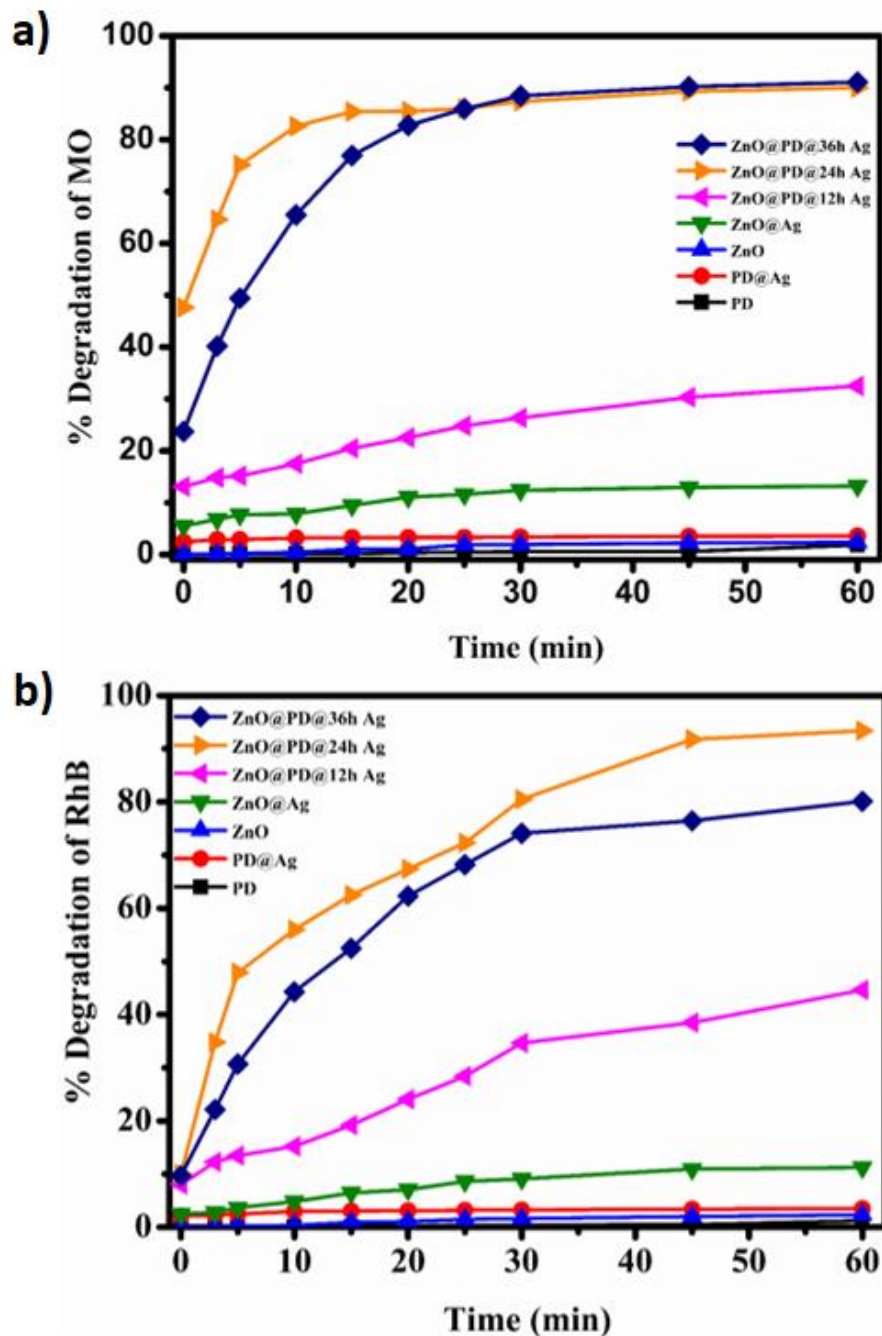


Figure 6. The degradation percentage of MO and RhB was changed by the Ag NSs growth; a) MO
b) RhB

The catalytic performance of the Ag decorated ZnO thin films depended on the Ag growth time. Figure 6 shows, the degradation percentage of MO and RhB was changed by the Ag NSs growth times. For substrates with PD, PD@Ag and ZnO thin films, the degradation percentage was below 20% for MO after 60 minutes, while for RhB it was below 10%. The degradation reaction proceeded rapidly in the case of substrates that involve both ZnO film and Ag NSs.

At the end of 15 min, for ZnO films that were decorated with Ag for 12h, 24h and 36h, the degradation percentage of the MO were 20%, 86% and 76%, whereas the degradation percentage of RhB were 19%, 62% and 53%, respectively. These results confirm the synergistic effect of the metal oxide thin films with plasmonic nanostructures. The maximum degradation was observed for 24h Ag deposition on ZnO thin film. For this film, the total degradation percentage was 90% at the end of 60 min. Although the maximum degradation was observed for the 24h Ag decorated sample at the end of the first 15 min, the total

degradation at the end of the 60 min was 91% with the 36h Ag decorated sample. We have also performed degradation experiments using different dye molecules.

Figure 7 compares the degradation percentage of 24h Ag decorated ZnO thin films in RhB and MO. At the end of the first 15 min., the degradation percentage of RhB was observed at 62%. In the experiments carried out here, at the end of 60 min., 90% degradation in MO and 94% degradation in RhB was observed. Consideration of these results with SEM images shows the importance of the size of the nanostructures for the catalytic performance. At the short growth times, there were no growth of Ag NSs, which resulted in low catalytic activity. In contrast, at longer growth times, the reduction in the size of Ag NSs led to decrease in the catalytic performance of the substrates.

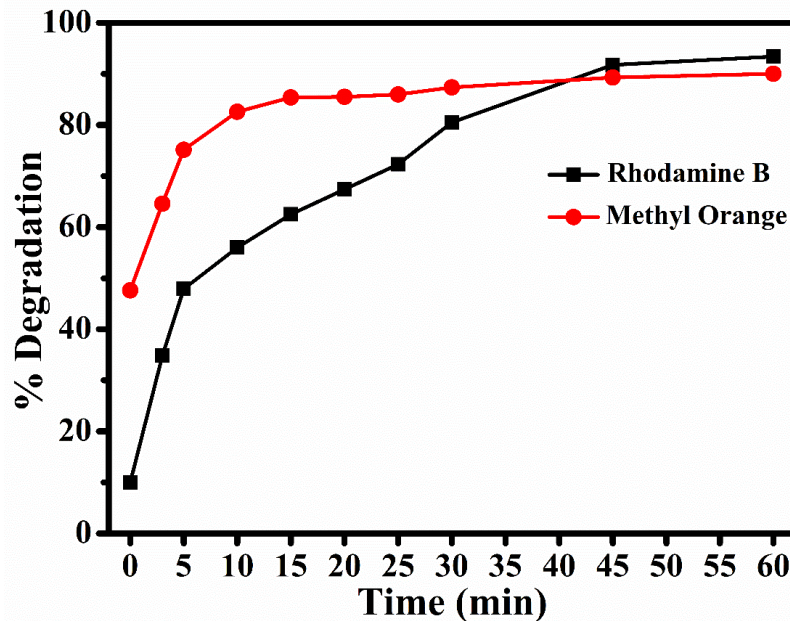


Figure 7. The degradation percentage of 24h Ag decorated ZnO thin films for RhB and MO

3.2. Degradation kinetics of methyl orange and rhodamine B

The kinetics of the catalytic degradation reaction of ZnO thin films decorated with Ag for 24 hours was analyzed using RhB and MO. The kinetic data of catalytic degradation of organic dyes with Ag decorated ZnO catalyst are analyzed by various models [29]. Langmuir-Hinshelwood mechanism forms the basis of these models [30]. The kinetics of heterogeneous catalytic systems given by Equation (2) are defined by Langmuir-Hinshelwood

$$\ln\left(\frac{C_0}{C}\right) + K(C_0 - C) = k_{app}Kt. \quad (2)$$

Here, C is the concentration of dye molecules after degradation, C_0 , initial concentration of dye molecules, K adsorption equilibrium constant, k_{app} apparent reaction rate constant and t catalytic processing time. In diluted ($C < 10^{-3}$ M) solutions, the reaction takes place in order to comply with the first order kinetics given by, since the KC in Equation (2) will be $\ll 1$

$$\ln\left(\frac{C}{C_0}\right) = -k_{app}t. \quad (3)$$

The absorbances of MO and RhB can be measured at approximately 464 nm and 554 nm, respectively. In this case, as a result of catalytic activity tests, the concentration values are calculated by Equation (4).

$$\ln\left(\frac{C}{C_0}\right) = \ln\left(\frac{A}{A_0}\right) = -k_{app}t, \quad (4)$$

where A is the initial absorbance of the dye molecules at 464 and 554 nm, and A_0 is the final absorbance. Figure 8 shows that the plot of $\ln(A/A_0)$ against degradation time for 24h Ag decorated ZnO thin films in Rhodamine B and Methyl Orange. As clearly seen from Figure 8, the degradation reactions correspond to the first-order reaction mechanism. The apparent reaction rate constant k_{app} , was calculated from the slope of the linear fit to the plot. The reaction rate constant was $33.8 \times 10^{-3} \text{ min}^{-1}$ for MO and $43.2 \times 10^{-3} \text{ min}^{-1}$ for RhB. The reaction rate constant of RhB is greater than reaction rate constant of MO. According to the degradation test results using 24h Ag decorated ZnO thin films, it was observed that the degradation of RhB is higher than MO.

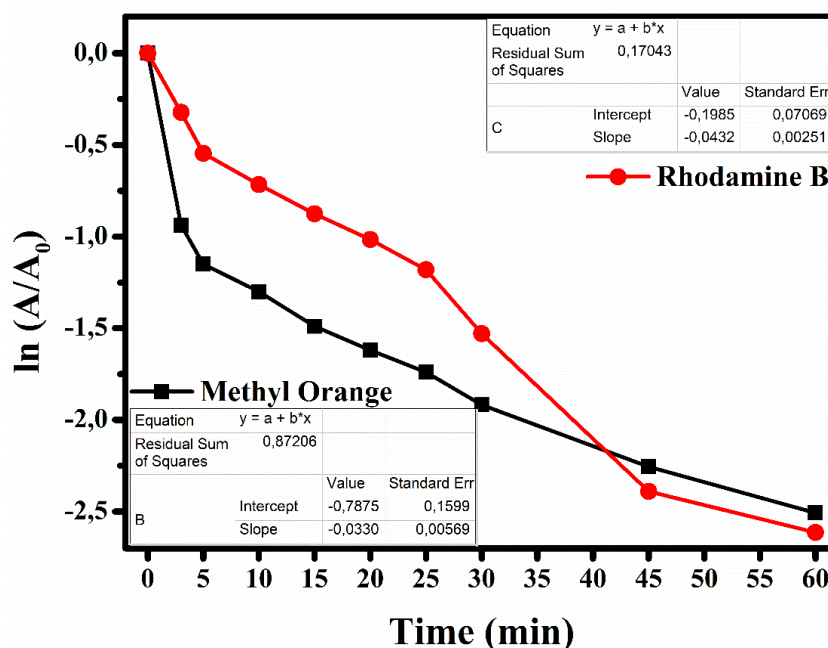


Figure 8. The variation of $\ln(A/A_0)$ as a function of time for 24h Ag decorated ZnO thin films in RhB and MO

A general mechanism for degradation of MO and RhB is shown in Figure 9. The catalytic degradation process is based on the transfer of electrons from the donor (NaBH_4) to the acceptor (MO and RhB). Simultaneous absorption of both dyes and BH_4^- ions on the surface of nanostructures is the beginning of degradation. When MO and RhB are reduced by NaBH_4 in the presence of catalyst, these dyes can decompose to form cationic species. The functional group of these dye molecules can be adsorbed on the surface of Ag@ZnO nanocomposites. As soon as BH_4^- ions supply electrons to Ag@ZnO nanocomposites, these electrons accumulate in Ag NPs and are trapped by adsorbed oxygen molecules to form O_2^* and $^*\text{OH}$ radicals [15, 20, 22]. These radicals react with the functional group of MO and RhB adsorbed, destroying the molecular structure of the dyes. This indicates that dyes (MO&RhB) and BH_4^- ions are absorbed simultaneously by Ag@ ZnO nanocomposites and catalysts facilitate electron transfer. As a result, electron charge transfer from BH_4^- ion to dyes can occur through Ag@ZnO nanocomposites. The high catalytic activity of Ag decorated ZnO samples is related to the irregular shapes of Ag nanostructures, large surface area /volume ratio and high surface area. These properties facilitate electron transfer and allow to exceed the kinetic barrier for the degradation reaction.

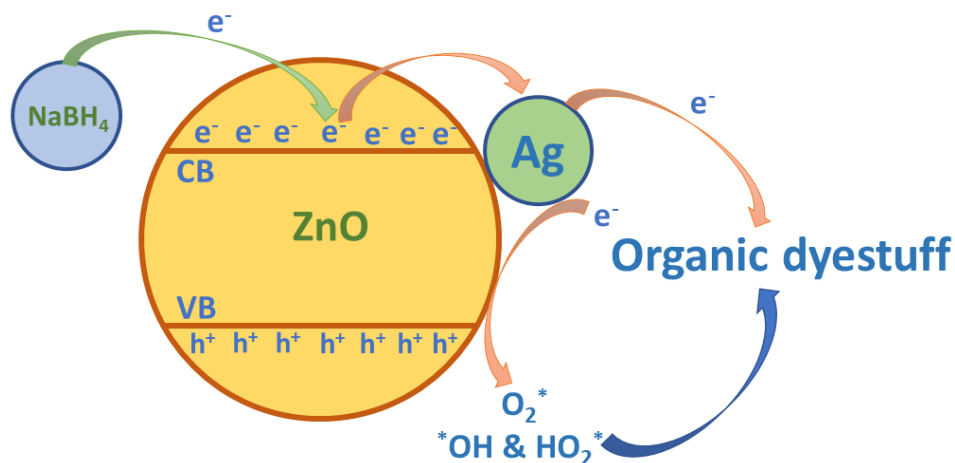


Figure 9. Catalytic reaction mechanism

4. CONCLUSION

Multi-functional surfaces were fabricated by physical vapor deposition of ZnO thin films followed by solution-phase PD mediated growth of Ag NSs. The synergistic effects between metal oxide semiconductor and plasmonic metallic nanostructures allowed for rapid degradation of two different types of organic dye molecules. The growth time of Ag NSs was important for obtaining high levels of degradation efficiency. The use of a universal surface functionalization agent, PD, offers the possibility of applying the presented approach to other types of metal oxide films and metallic structures. The ease of separation and possibility of reusing the substrates are the key advantages of solid substrates for degradation applications.

CONFLICTS OF INTEREST

No conflict of interest was declared by the authors.

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